PTO/SB/084(10-01)
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INFORMATION DISCLOSURE STATEMENT BY APPLICANT (Use as many sheets as necessary)	Application Number	10/081,818	
	Filing Date	February 20, 2002	
	First Named Inventor	Eldridge, Jerome	
	Group Art Unit	2818	
	Examiner Name	Ho, Tu-Tu	
Sheet 1 of 1	Attorney Docket No: 1	303.045US1	

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Application Number	10/081,818
Filing Date	February 20, 2002
First Named Inventor	Eldridge, Jerome
Group Art Unit	2818
Examiner Name	Ho, Tu-Tu

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Examiner initials*	Cite No ¹	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published.	T
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DATE CONSIDERED

02/28/2007

10/081.818 IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

PATENT

Applicant:

Jerome M. Eldridge et al.

February 20, 2002

Examiner: Tu-Tu V. Ho

Serial No.:

10/081,818

Group Art Unit: 2818

Filed:

Docket: 1303.045US1

Title:

ATOMIC LAYER DEPOSITION OF METAL OXIDE AND/OR LOW

ASYMMETRICAL TUNNEL BARRIER INTERPOLY INSULATORS

COMMUNICATION CONCERNING RELATED APPLICATIONS

MS Amendment

Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

Noted, Feb. 07 Applicants would like to bring to the Examiner's attention the following related applications in the above-identified patent application:

TH	Serial/Patent No. 11508090	Filing Date/Issue Date August 22, 2006	Attorney Docket 1303.024US4	Title FLOATING GATE STRUCTURES
TH	11590363	October 31, 2006	1303.014US3	FLASH MEMORY WITH LOW TUNNEL BARRIER INTERPOLY INSULATORS
TH	11565826	December 1, 2006	1303.141US2	HAFNIUM TITANIUM OXIDE FILMS
TH	11619080	January 2, 2007	1303.027US4	IN SERVICE PROGRAMMABLE LOGIC ARRAYS WITH LOW TUNNEL BARRIER INTERPOLY INSULATORS

Continuations and divisionals may be later filed on the cases listed above, or cited to the Examiner in any previous Communication Concerning Related Applications. Applicants request that the Examiner review all continuations and divisionals of the above-listed or previously-cited patent applications before allowing the claims of the present patent application.

Respectfully submitted,

JEROME M. ELDRIDGE ET AL.

By Applicants' Representatives,

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CERTIFICATE UNDER 37 CFR 1.8: The undersigned hereby certifies that this correspondence is being deposited with the United States Postal Service with sufficient postage as first class mail, in an envelope addressed to: MS Amendment, Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313-1450, on this day of February, 2007.